



Practitioner's Docket No. 101109.0003US2

**PATENT**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of: Liu, Heng

Application No.: 10/727,746

Filed: December 3, 2003

For: Chemical Vapor Deposition Reactor

Group No.:

Examiner:

**Commissioner for Patents**

**P.O. Box 1450**

**Alexandria, VA 22313-1450**

**TRANSMITTAL OF INFORMATION DISCLOSURE STATEMENT  
WITHIN THREE MONTHS OF FILING OR  
BEFORE MAILING OF FIRST OFFICE ACTION (37 C.F.R. § 1.97(b))**

**IDENTIFICATION OF TIME OF FILING THE ACCOMPANYING  
INFORMATION DISCLOSURE STATEMENT**

The information disclosure statement submitted herewith is being filed within three months of the filing date of the application or date of entry into the national stage of an international application or before the mailing date of a first Office action on the merits, whichever event occurs last. 37 C.F.R. § 1.97(b).

Date: 20 Jan 04

Reg. No.: 30455

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Signature of Practitioner

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**CERTIFICATE OF FIRST CLASS MAILING (37 C.F.R. Section 1.10/1.8(a))**

I hereby certify that this paper (along with any paper referred to as being attached or enclosed) is being deposited with the United States Postal Service on the date shown below with sufficient postage as First Class Mail in an envelope addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

Date: 1/20/04

  
\_\_\_\_\_  
Barbara Hayashi

<b>LIST OF REFERENCES CITED BY APPLICANT</b> (Use several sheets if necessary)		ATTY. DOCKET NO. 101109.0003US2	SERIAL NO. 10/727746
	APPLICANT Heng Liu		
	FILING DATE December 3, 2003		GROUP

#### U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	AA	4961399	10/9/1990	Frijlink			
	BB	6113705	9/5/2000	Ohashi, et al.			
	CC	6197121	3/6/2001	Gurary, et al.			
	DD	6080241	6/21/2000	Li et al.			
	EE	4980204	12/25/1990	Fujii, et al.			
	FF						
	GG						
	HH						
	II						

#### FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO
	JJ							
	KK							
	LL							
	MM							
	NN							

#### OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, Etc.)

	OO	
	PP	
	QQ	

EXAMINER

DATE CONSIDERED

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.